10/791.259 H1547

## Amendments to the Claims

Please amend the claims as in the following listing:

- (Original) A method of selective exposure of a resist, comprising: providing radiation having a cross-section shape that is asymmetric; reflecting the asymmetric radiation off a reflective reticle; and directing the asymmetric radiation to the resist.
- (Original) The method of claim 1, wherein the providing includes providing asymmetric radiation that has a greater range of angle incidence in a first direction than in a second direction that is perpendicular to the first direction.
- (Original) The method of claim 2, wherein the ratio of the range of the angle incidence between the first direction and the second direction is greater than 1.
- (Original) The method of claim 1, wherein the providing includes providing asymmetric radiation that has an elliptical shape in phase space.
- (Original) The method of claim 1, wherein the providing includes providing asymmetric radiation that has an elliptical ring shape in phase space.
- 6. (Original) The method of claim 5, wherein the elliptical ring shape has a substantially uniform ring width.
- (Original) The method of claim 5, wherein the elliptical ring shape has a nonuniform ring width.

10/791,259 H1547

8. (Original) The method of claim 1, wherein the providing includes transforming symmetric radiation to the asymmetric radiation.

- (Currently Amended) The method of claim 8, wherein the transforming includes reflecting the symmetric radiation off of a mirror to produce the asymmetric radiation
- (Original) The method of claim 9, wherein the reflecting off the mirror includes reflecting off a fly's eye mirror having a plurality of facets.
- 11. (Original) The method of claim 9, wherein the reflecting off the mirror includes reflecting off a fixed mirror.
- 12. (Original) The method of claim 8, wherein the transforming includes passing the radiation through one or more lenses to produce the asymmetric radiation.
- 13. (Original) The method of claim 8, wherein the transforming includes passing the symmetric radiation through one or more slits to produce the asymmetric radiation.
- 14. (Original) The method of claim 8, wherein the symmetric radiation includes non-coherent radiation from a laser source
- 15. (Currently Amended) The method of claim 1, wherein the reflecting off the reticle includes reflecting the asymmetric radiation at an average angle of incidence <u>relative to the reticle</u>, and

wherein asymmetry in the asymmetric radiation substantially compensates for

10/791,259 H1547

bias in pattern transfer from the reticle to the resist due to the average angle of incidence.

- 16. (Original) The method of claim 15, wherein the providing includes changing the asymmetry of the asymmetric radiation in response to changes in the average angle of incidence.
- 17. (Original) The method of claim 15, wherein the average angle of incidence is between about 2 degrees and about 8 degrees.
- 18. (Original) The method of claim 1, wherein the asymmetric radiation includes extreme ultraviolet radiation having a wavelength between about 3 nm and about 70 nm.

19 and 20. (Canceled)